



09/902,483

YOR919990408CIP

1

2813 ~~A~~
JFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Cabral et al.

Serial No.: 09/902,483

Group Art Unit: 2813

Filed: July 11, 2001

Examiner: Erik Kielin

For: SELF-ALIGNED SILICIDE (SALICIDE) PROCESS FOR LOW RESISTIVITY
CONTACTS TO THIN FILM SILICON-ON-INSULATOR AND BULK MOSFETS
AND FOR SHALLOW JUNCTIONS

Honorable Commissioner of Patents
Alexandria, VA 22313-1450

RESPONSE UNDER 37 C.F.R. §1.111

Sir:

In response to the Office Action dated May 25, 2004, please amend the above- identified
application as follows:

INTRODUCTORY COMMENTS

There are no amendments to the Claims. However, for the Examiner's convenience,
attached is a listing of the pending claims which begins on page 2 of this paper. **Remarks** begin
on page 10 of this paper.